

<b>Notice of Allowability</b>	<b>Application No.</b>	<b>Applicant(s)</b>	
	10/652,026	YOSHIMURA ET AL.	
	Examiner Sun J. Lin	Art Unit 2825	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--

All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. **THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS.** This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.

1.  This communication is responsive to Amendment & Remarks filed on 01/04/2005.
2.  The allowed claim(s) is/are 1-12, renumbered (37CFE1.126).
3.  The drawings filed on 02 September 2003 are accepted by the Examiner.
4.  Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
  - a)  All      b)  Some\*      c)  None      of the:
    1.  Certified copies of the priority documents have been received.
    2.  Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
    3.  Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

\* Certified copies not received: \_\_\_\_\_

Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  
**THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.**

5.  A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.
  6.  CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.
    - (a)  including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached
      - 1)  hereto or 2)  to Paper No./Mail Date \_\_\_\_\_.
    - (b)  including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date \_\_\_\_\_.
- Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).
7.  DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.

#### Attachment(s)

1.  Notice of References Cited (PTO-892)
2.  Notice of Draftperson's Patent Drawing Review (PTO-948)
3.  Information Disclosure Statements (PTO-1449 or PTO/SB/08),  
Paper No./Mail Date \_\_\_\_\_
4.  Examiner's Comment Regarding Requirement for Deposit  
of Biological Material
5.  Notice of Informal Patent Application (PTO-152)
6.  Interview Summary (PTO-413),  
Paper No./Mail Date \_\_\_\_\_.
7.  Examiner's Amendment/Comment
8.  Examiner's Statement of Reasons for Allowance
9.  Other \_\_\_\_\_.

### ***Reasons for Allowance***

Claims 1 – 12 are allowed over the prior art of record. An examiner's statement of reasons for allowance is given in the following:

Claims 4, 8 and 12 are allow due to allowable subject matter as explained in the Office Action mailed to applicants on 10/05/2004.

Claims 1 – 3, 5 – 7 and 9 – 11 are allowed because the prior art does not teach or fairly suggest the following subject matter:

- A reticle fabrication method comprising the step of *converting CAD data which is reticle design data to electron beam write data by means of a first data conversion device and to inspection data by means of a second data conversion device, comparing said electron beam write data with said inspection data in a data verification device to verify whether or not there is a data conversion error in combination with other limitations as recited in independent Claim 1;*
- A reticle fabrication method comprising the step of *converting first electron beam write data for writing a figure pattern on a reticle based on reticle design data to second electron beam write data by means of a first data conversion device and to inspection data by means of a second data conversion device, comparing said second electron beam write data with said inspection data in a data verification device to verify whether or not there is a data conversion error in combination with other limitations as recited in independent Claim 2;*
- A reticle fabrication method comprising the step of *converting CAD data which is reticle design data to electron beam write data by means of a first data conversion device, comparing said electron beam write data with said CAD data in a data verification device to verify whether or not there is a data conversion error in combination with other limitations as recited in independent Claim 3.*

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance".

***Conclusion***

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sun J. Lin whose telephone number is (571) 272 – 1899. The examiner can normally be reached on Monday to Friday from 9:30am to 6:30pm.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-1782.

Sun J. Lin  
Patent Examiner  
Art Unit 2825  
March 24, 2005

**STACY A. WHITMORE  
PRIMARY EXAMINER**

